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FOR RELIABLE SYSTEMS

Reliability assessment of RF MEMS switches

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1- NOVA MEMS, 2- CNES, 3- MEMSCAP

7th ESA Round Table on MNT for Space Apps



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Outline

- Introduction
- Approaches for Reliability assessment
- Accelerated aging
- Physics of Failure
- Conclusion



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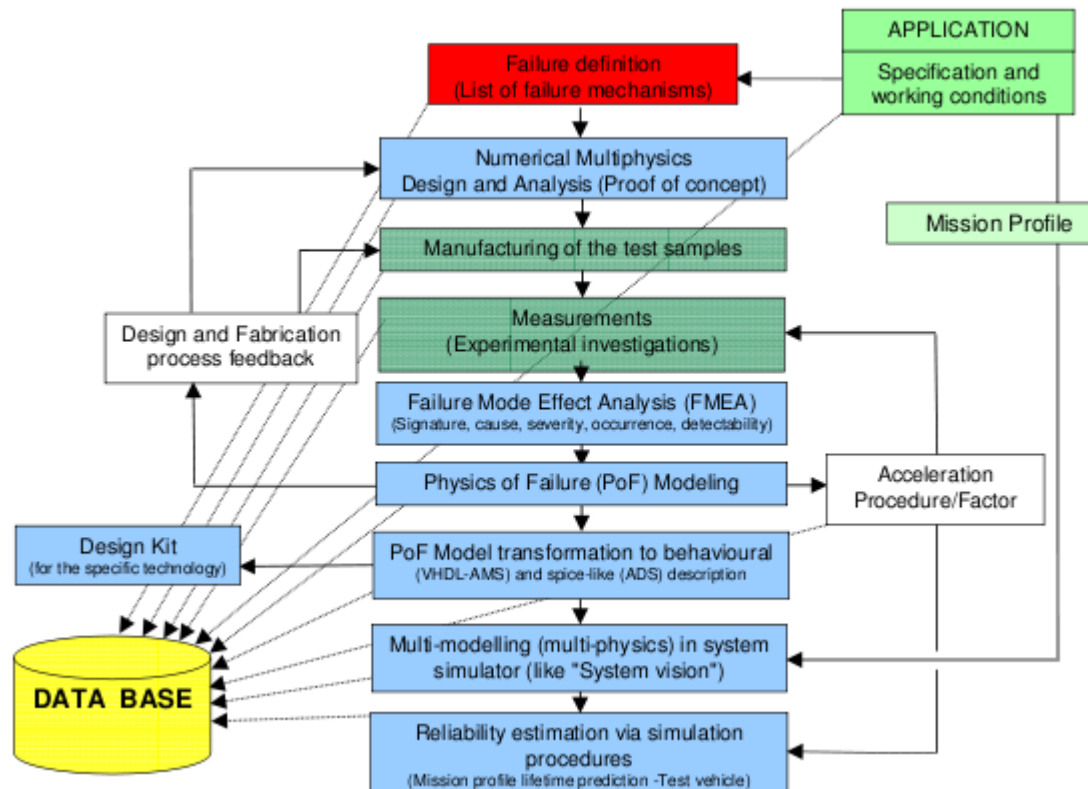
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The POLYNOE EDA Project

- Aim: Prove the Physics of Failure concept for reliability assessment of MEMS switches





Introduction

- Several technologies for switching operation

	MESFET	PIN Diode	MEMS
Series Resistance (Ω)	3 to 5	1	< 1
Loss @1GHz (dB)	0.5 to 1.0	0.5 to 1.0	0.1
Isolation @1GHz (dB)	20 to 40	40	> 40
IP3 (dBm)	40 to 60	20 to 45	60
1 dB compression (dBm)	20 to 35	20 to 35	20 to 35
Size (mm ²)	1 to 5	1 to 5	1 to 5
Switching speed	~ ns	~ μ s	~ μ s
Control Voltage (V)	8	3 to 5	3 to 30
Control Current	< 10 μ A	10 mA	< 10 μ A

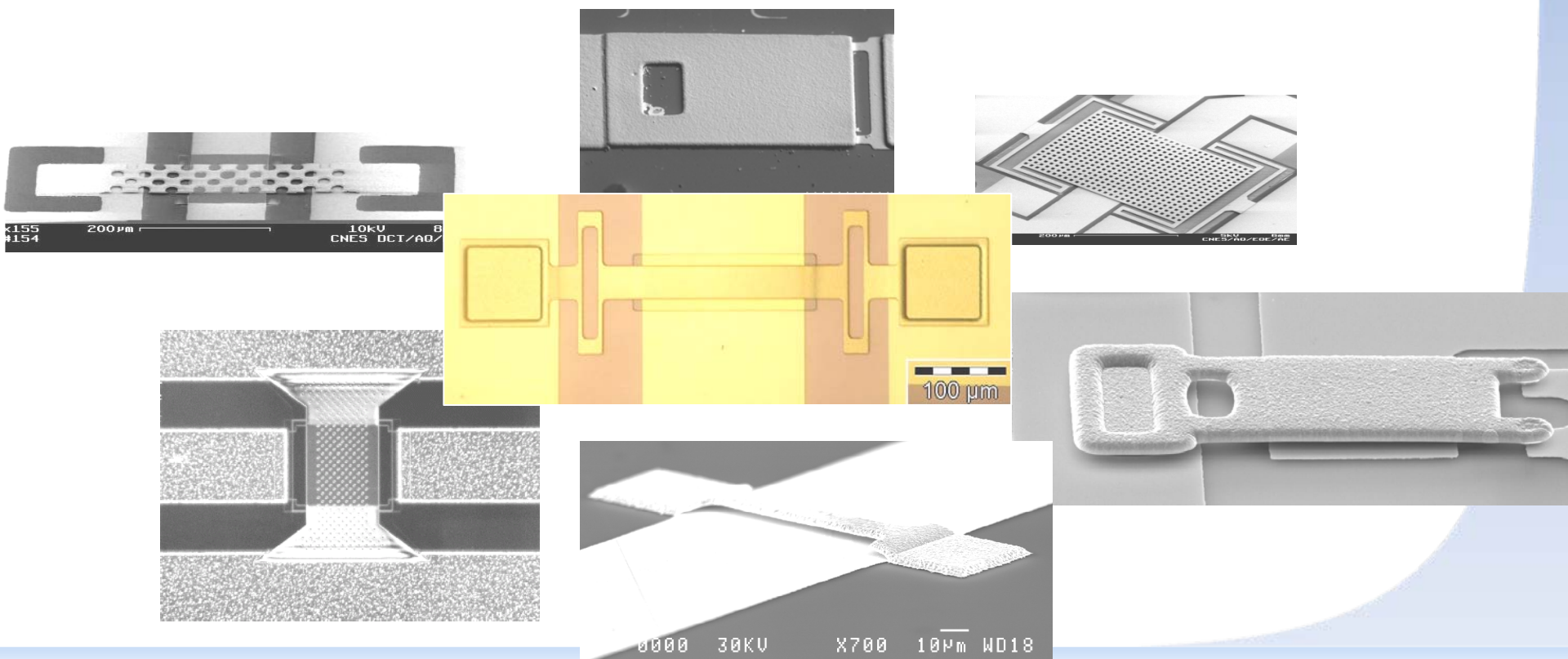
XLIM Lab:
Nanogap switches
 (a few tens of nanoseconds !)



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Introduction

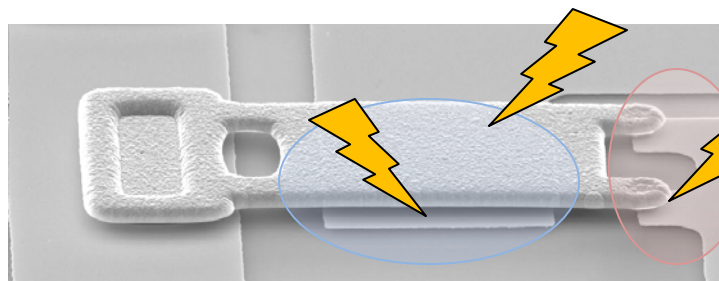
- Research on contact characterization for MEMS switches driven by the necessity to reach a high-reliability level for micro switch applications





Introduction

- Research on contact characterization for MEMS switches driven by the necessity to reach a high-reliability level for micro switch applications



Mechanical system:

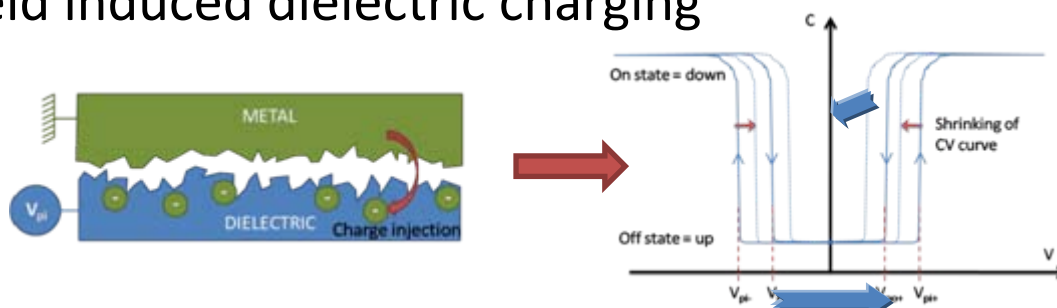
- Actuation
- Contact line



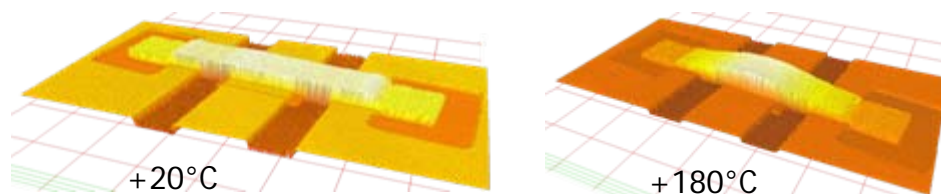
Introduction

- FMEA: identification of the main failure mechanisms

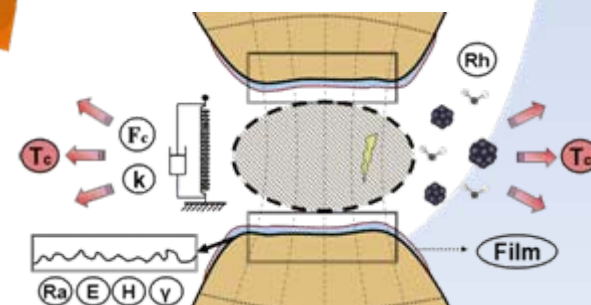
- » Field induced dielectric charging



- » Temperature induced deformation of the structures



- » Degradation of the electrical micro-contact





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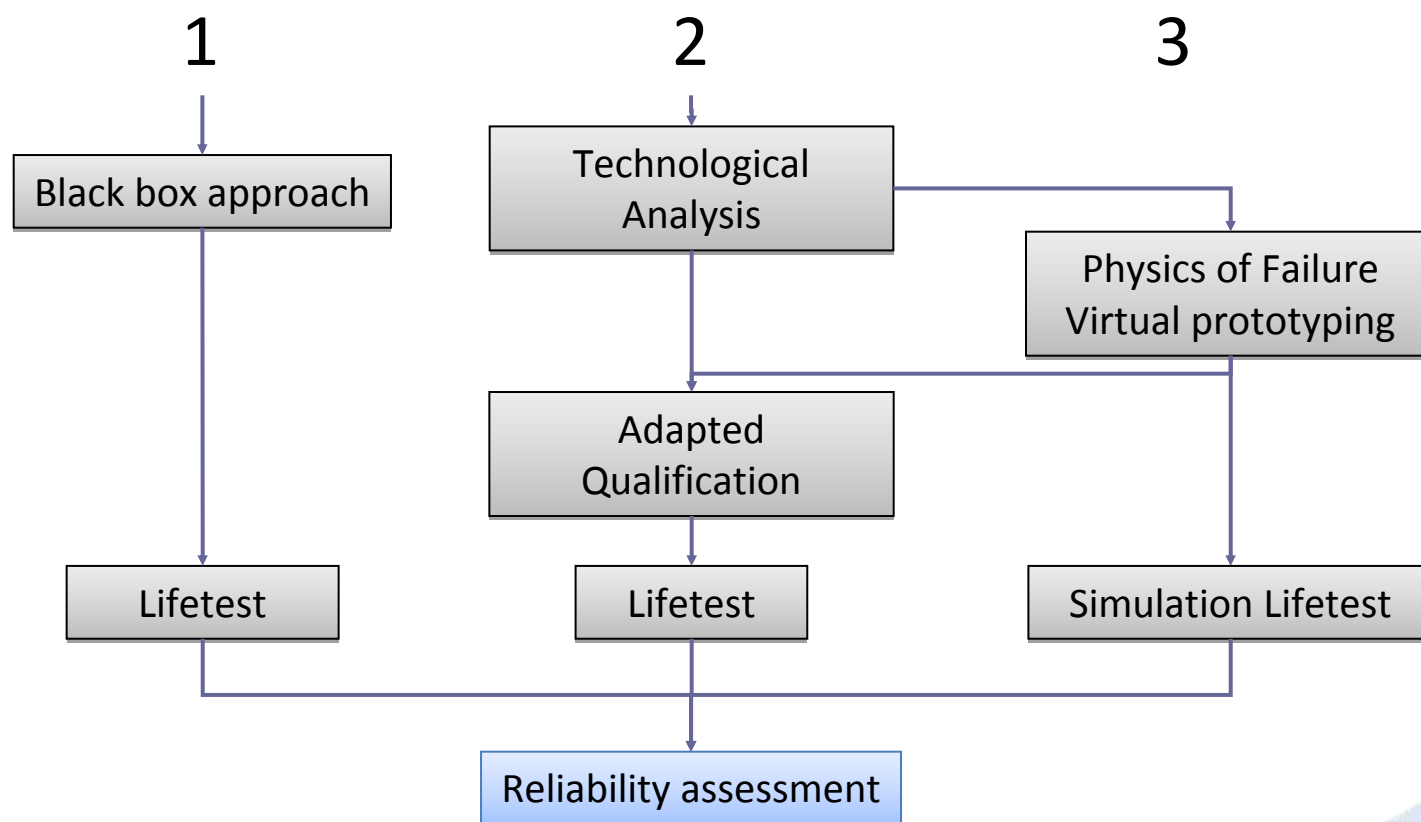
- Introduction
- **Approaches for Reliability assessment**
- Accelerated aging
- Physics of Failure
- Conclusion



Reliability assessment

- Several approaches

COTS





Reliability assessment

- Blackbox approach: “RF Switches as a black box”.
 - Unknown die / design / materials / technological parameters
 - Observation only at I/O
 - Stress / stimuli is applied according to mission profile (with margins)
 - GO/NOGO Results

☹ ! Switch as a device

We should considered it as a system → study of the failure mechanisms of subsystems (moving part, electrical contact...)

☹ ! Accelerated aging: inputs ?

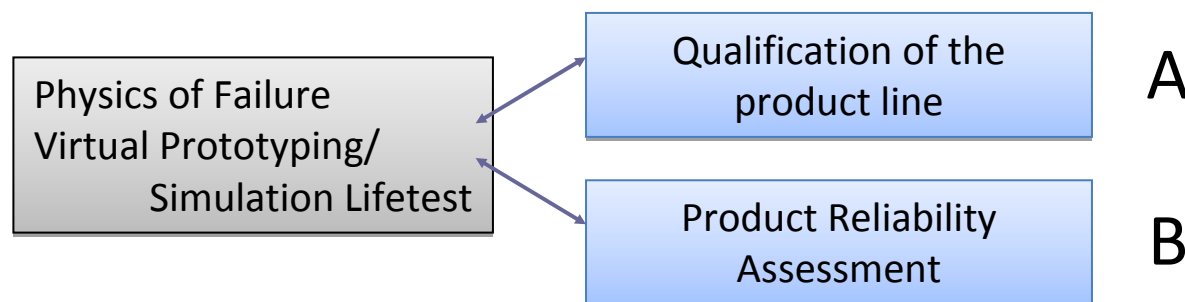
☹ ! Statistical approach → irrelevant for dvpt of new technologies.



Reliability assessment

- Several approaches

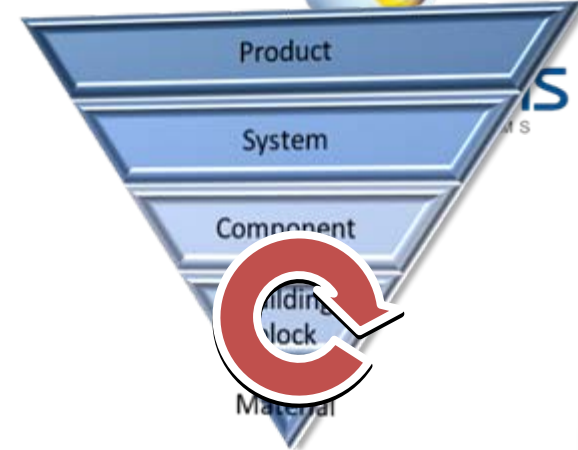
New Component





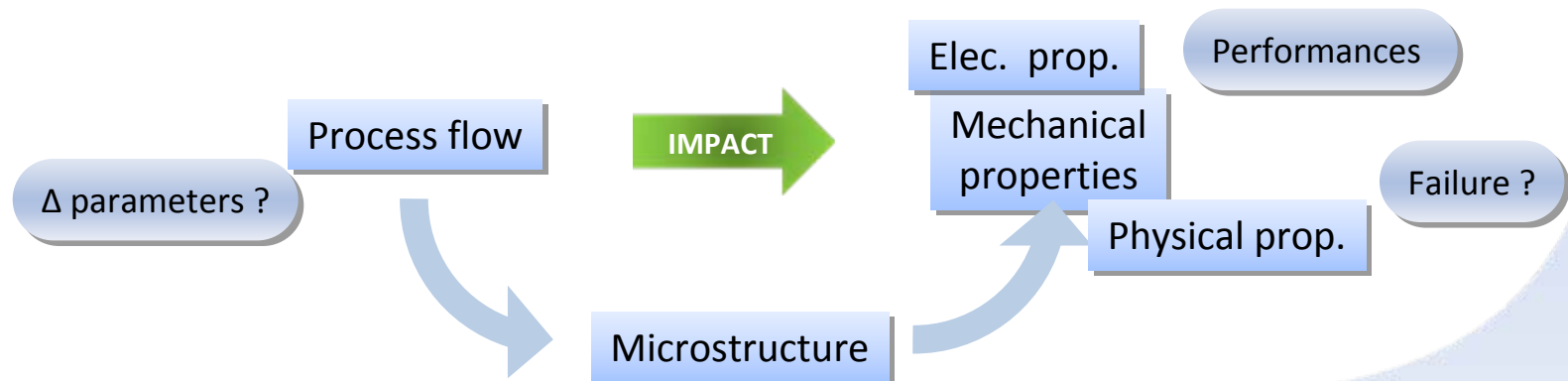
Reliability assessment

- New technologies: Production line ?
Materials & Design



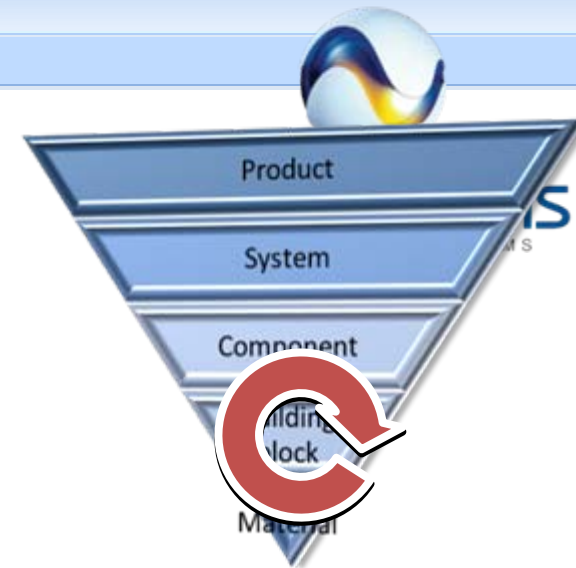
The mechanical properties differ from MacroWorld:

- Strong interaction between microstructural features and the geometry of the thin coatings (eg. Thicknesses)
- Microstructural properties greatly influenced by the process (kind of deposition, temperatures, sacrificial layers...)



Reliability assessment

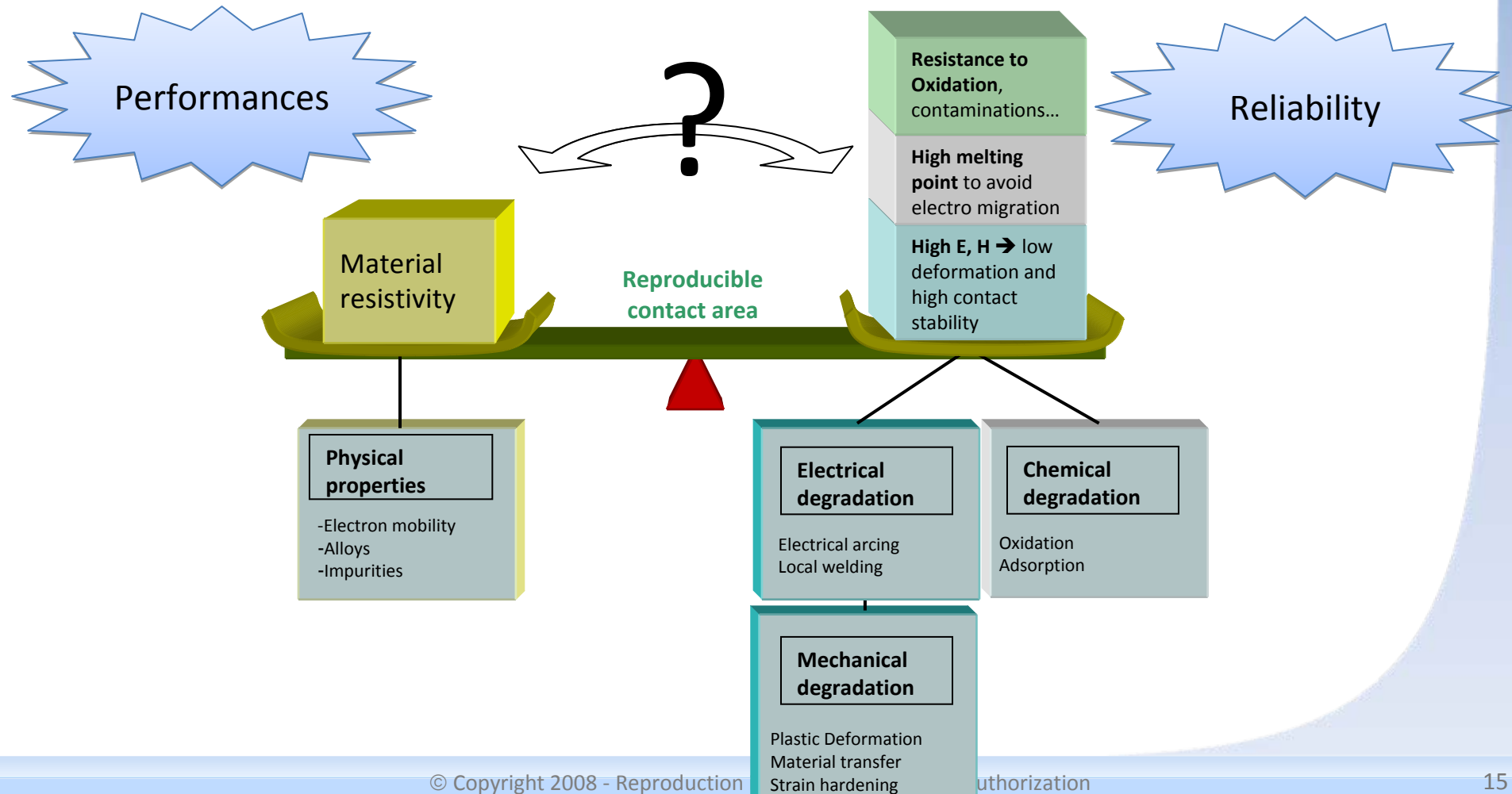
- Design for reliability
 - » Working on the very first blocks
 - » Use feedback for the design of new comp.





Reliability assessment

- Design for reliability: necessity of trade-offs





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Accelerated aging

- Creep (1/2)

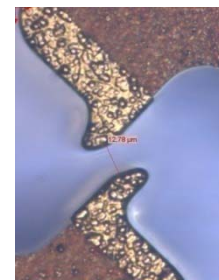
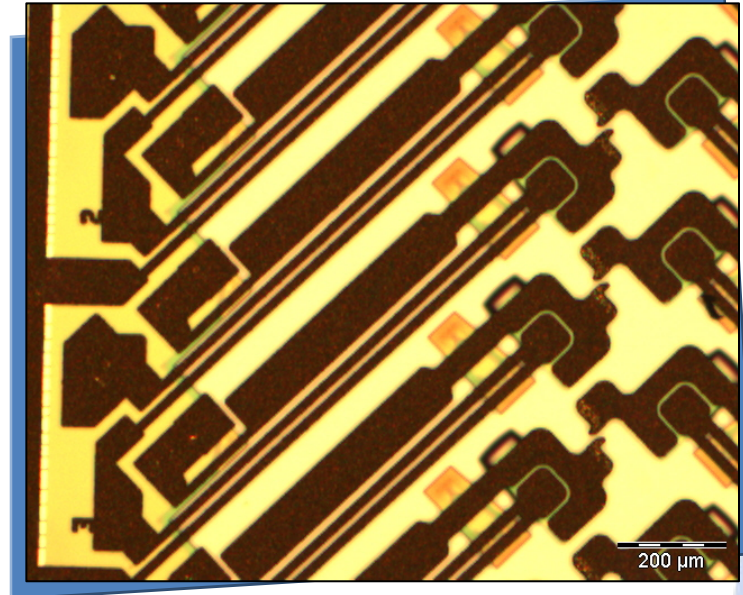
- » Model:

$$\dot{\varepsilon} = A \frac{\sigma^n}{d^p} \exp\left(-\frac{Q}{RT}\right)$$

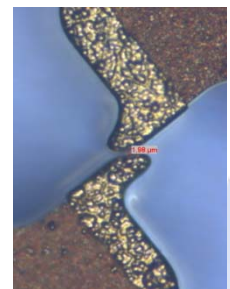
- Power law for secondary creep (n is the creep exponent)
 - Arrhenius acceleration factor (Q is the activation energy)

- » Experiment

- Characterization of thermally actuated MEMS switches (MEMSCAP, EDA POLYNOE program)
 - Loss of isolation with cycles: gap between the electrodes



Before

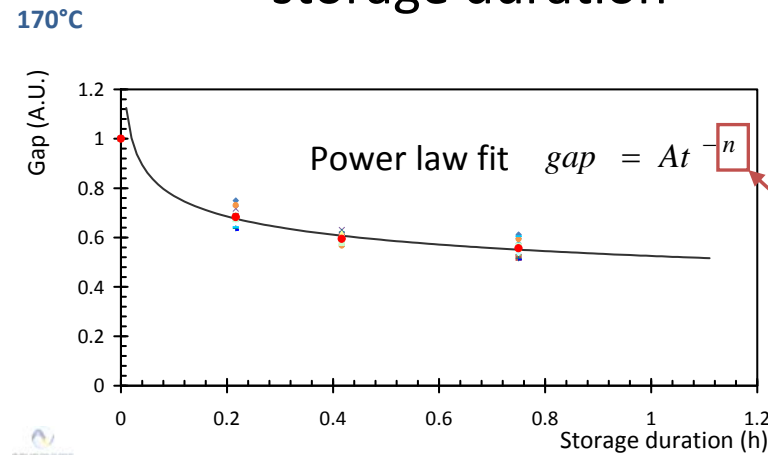


After 3 weeks @150°C
(closed position)

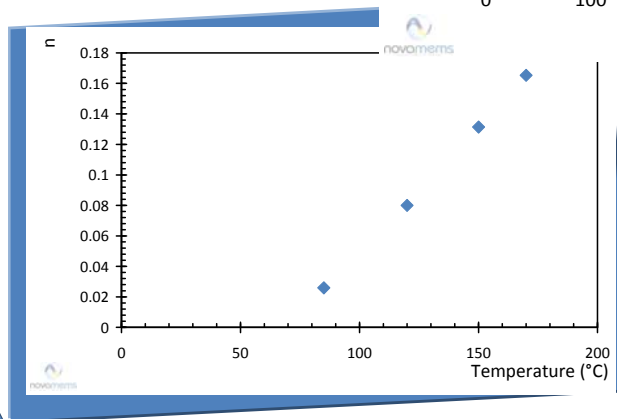
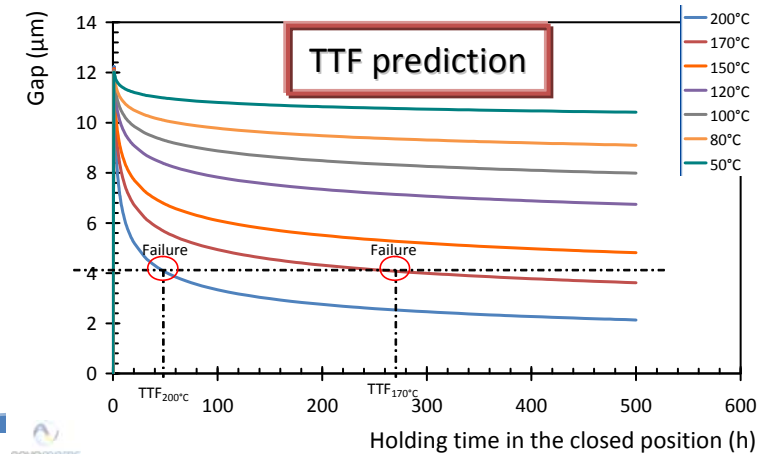


Accelerated aging

- Creep (2/2)
 - » Modelling the evolution of the gap with temperature and storage duration



n versus T°

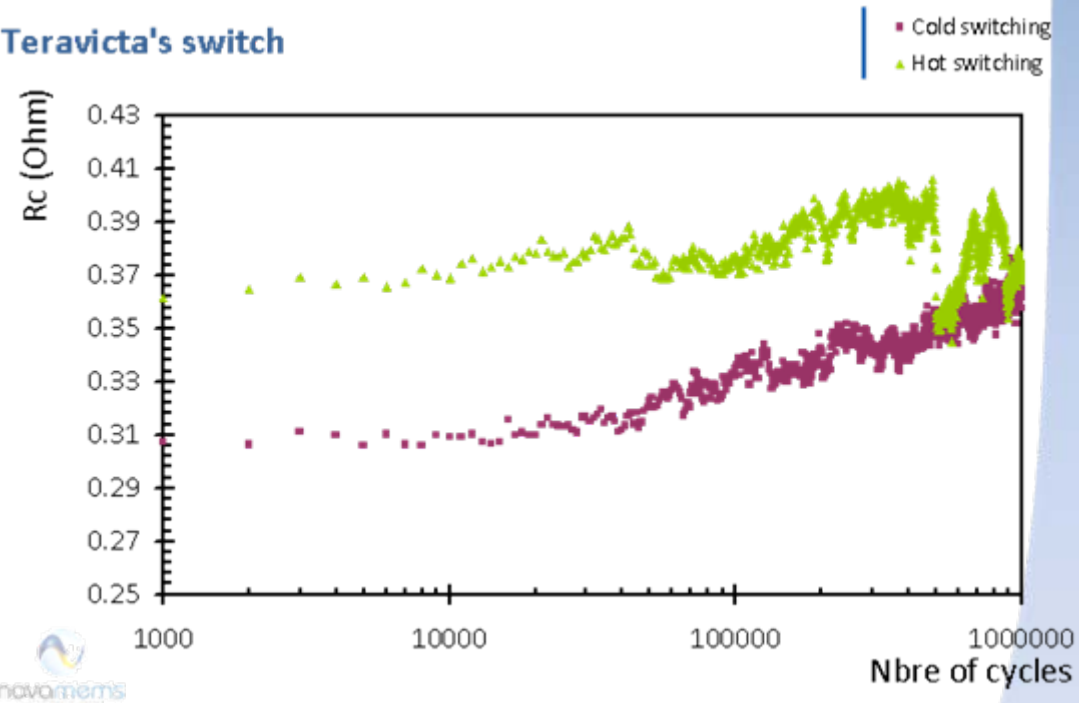




Accelerated aging

- Cycling
 - » Great influence of the testing method on the reliability
 - Progressive increase of the contact resistance for cold switching
 - Erratic behaviour in hot switching

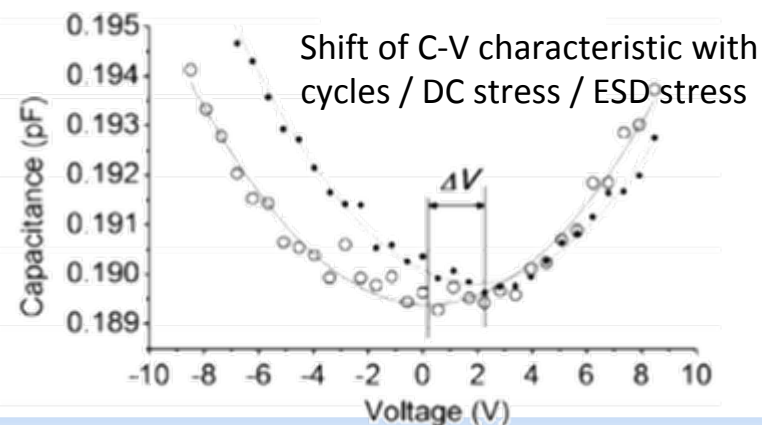
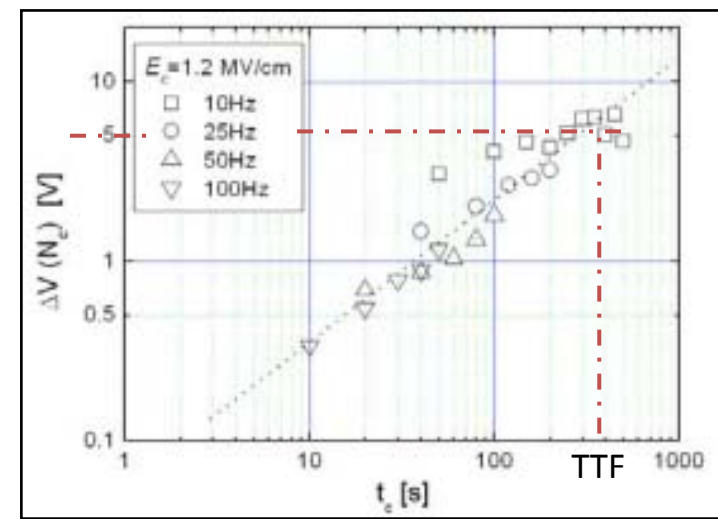
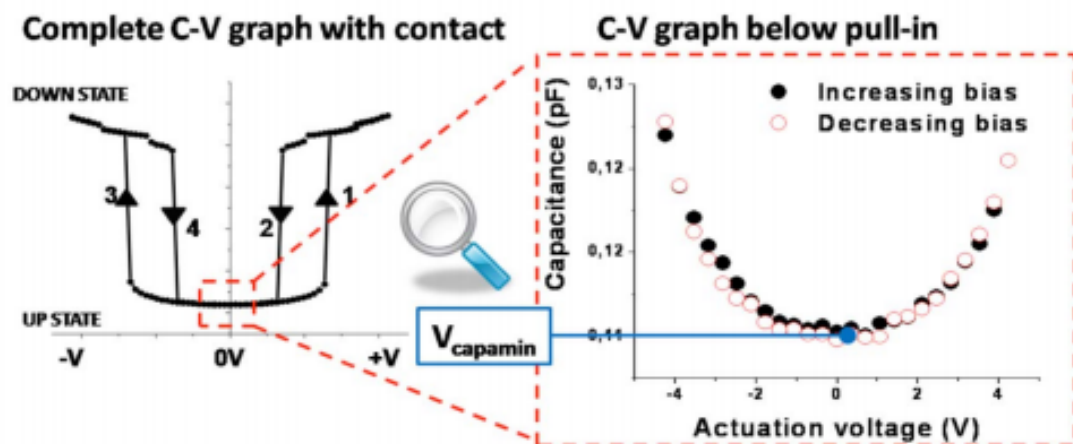
Teravicta's switch





Accelerated aging

- DC Stress / ESD aging for charging effect quantification



J. Ruan et al. (LAAS-CNRS) : FAME (ANR) project



Accelerated aging

- Radiations
 - » Expected effects: Damage of the dielectric layer
 - modification of V_{pi}/V_{po}
 - Increase of leakage current
 - Single event transient: auto-actuation



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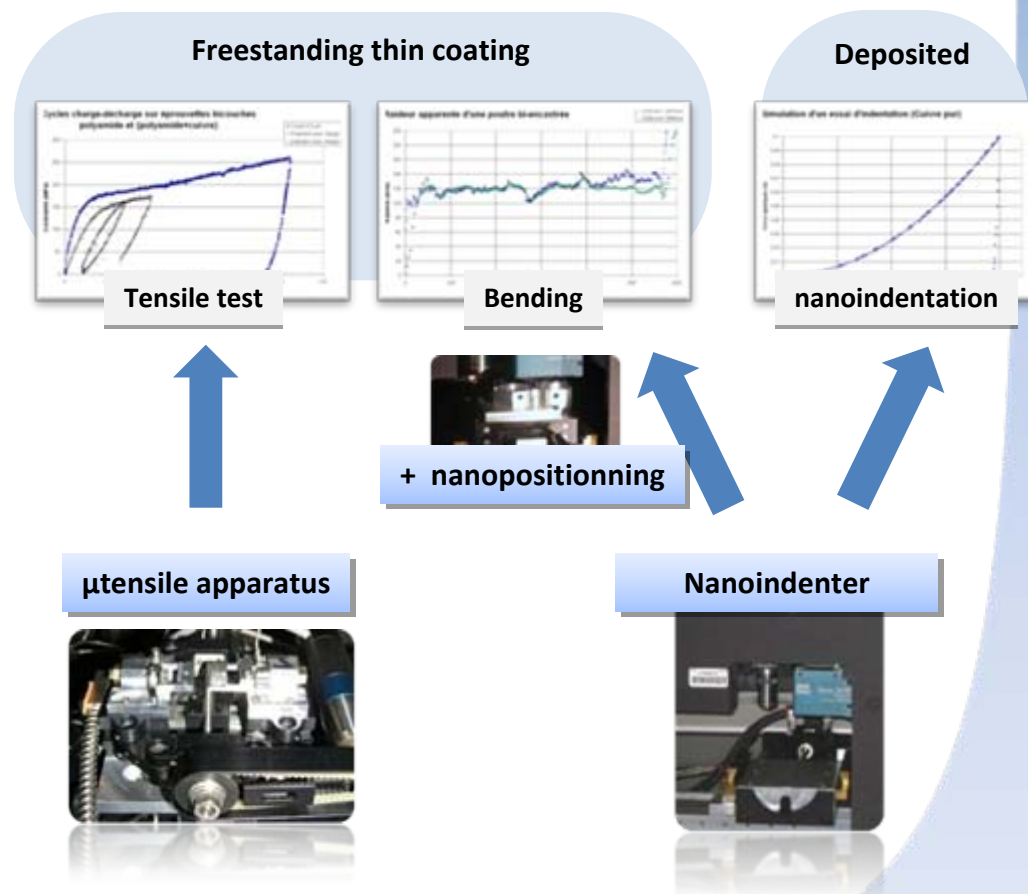
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Physics of Failure

- **Material level**

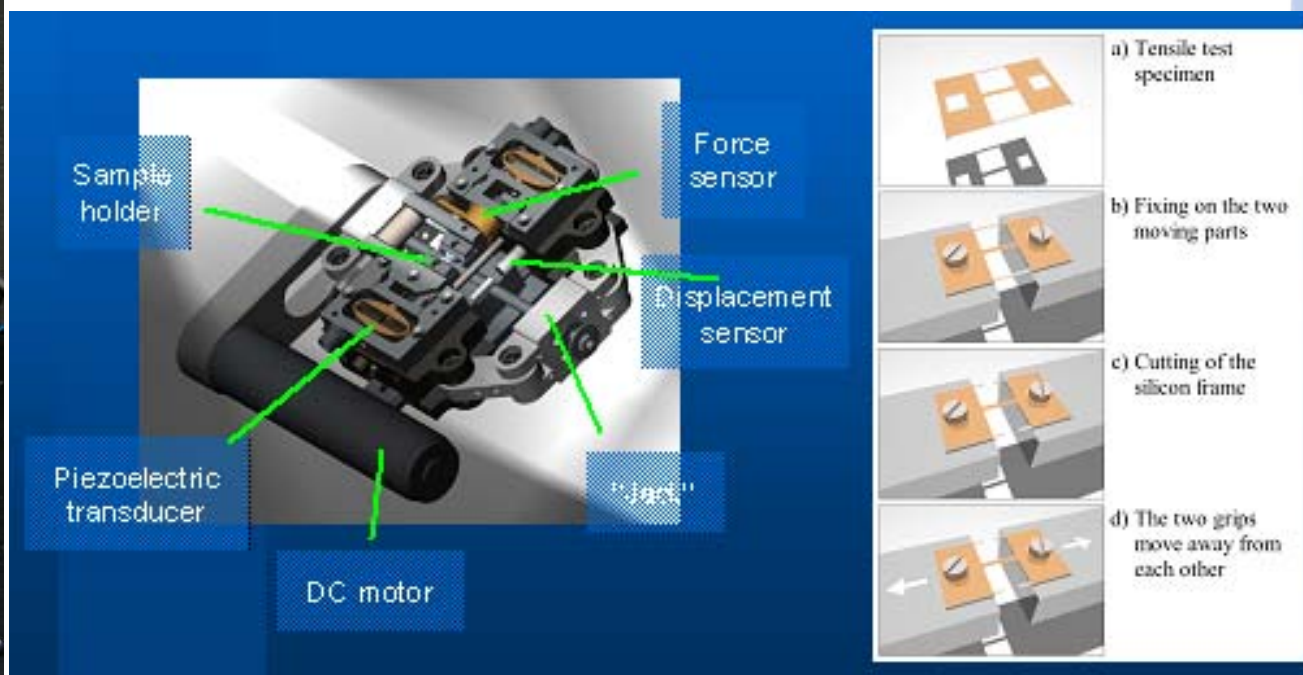
- » Evaluate the mechanical properties through mechanical actuation of dedicated specimens
- » Wide range of materials
 - Metals (and alloys)
 - Ceramics
 - Polymers
- » Deposited on substrate or freestanding thin coatings





Physics of Failure

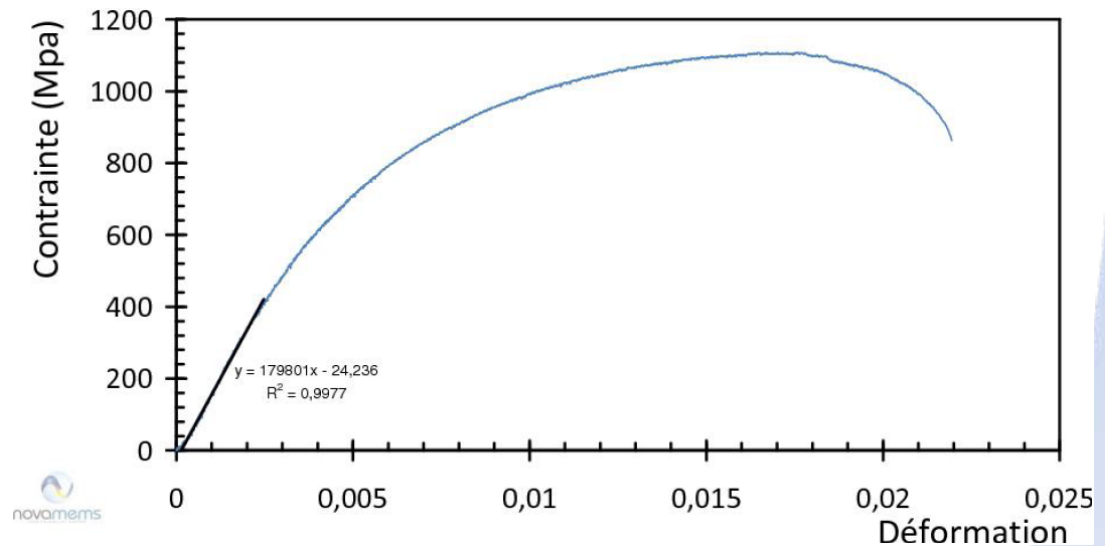
- Micro- tensile experiments
 - » Home-made Developments (NOVA MEMS : C. Seguineau), in collaboration with SIMaP Laboratories (M. Ignat) and INL (C. Malhaire)





Physics of Failure

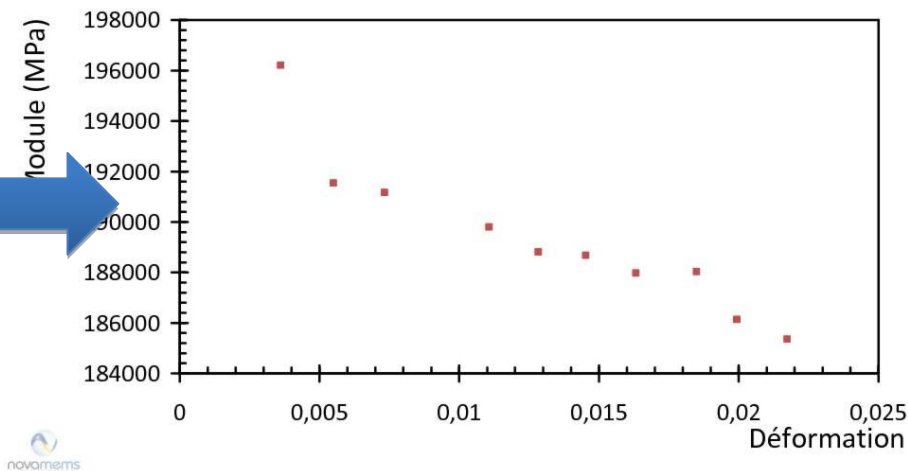
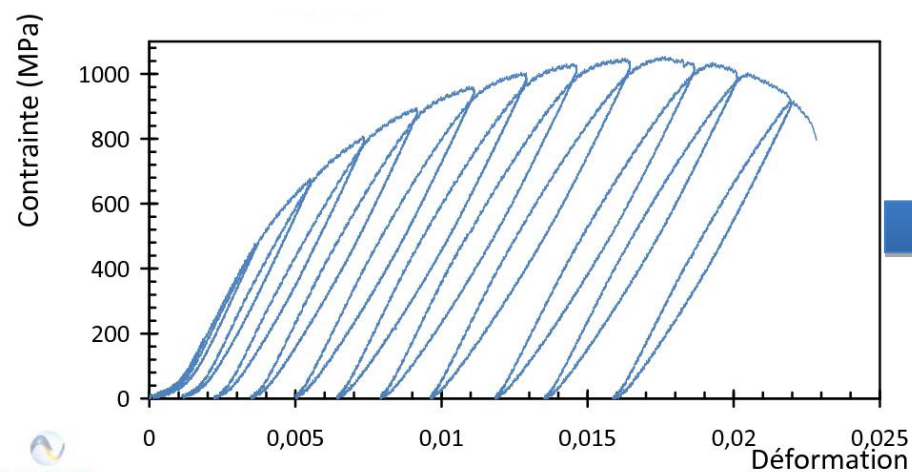
- Material level: μ tensile test on NiCo specimens (MEMSCAP)
 - » Monotonic experiments
 - Young's modulus
 - Yield stress
 - Strain hardening
 - Ultimate strength





Physics of Failure

- Material level: μ tensile test on NiCo specimens (MEMSCAP)
 - » Multicycle experiments: Damage assessment

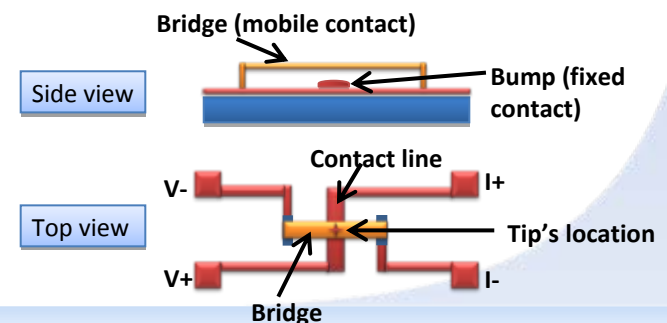
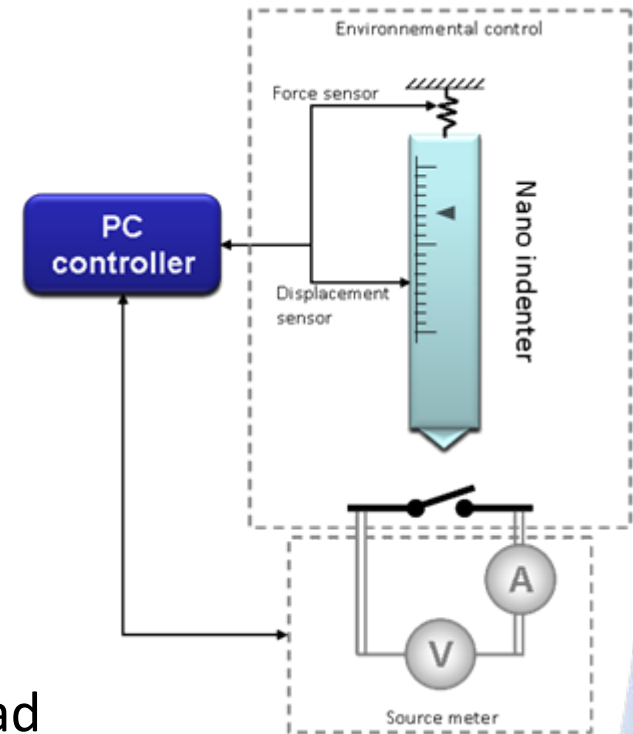




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Physics of Failure

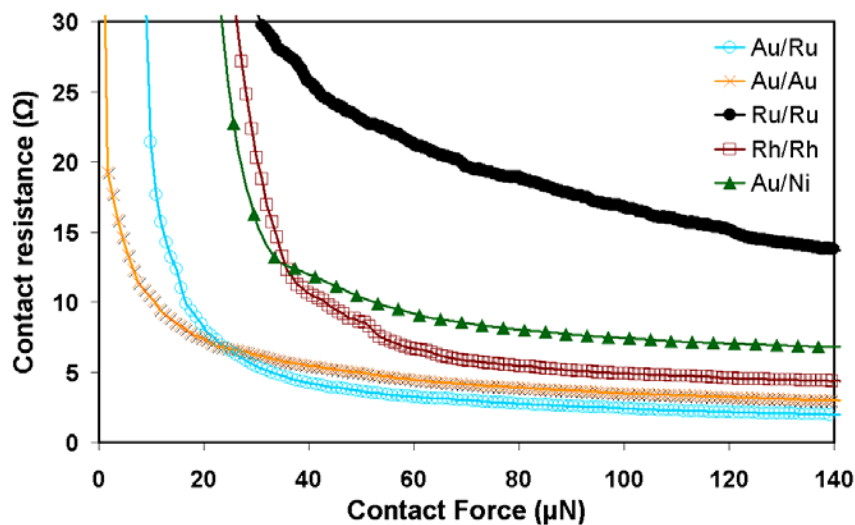
- Electrical contact (subsystem level)
 - » Monitoring R_c evolution versus:
 - Intensity I
 - Load applied F
 - Compliance level U
 - Switching mode (mechanical, cold, hot)
 - Number of cycles n
 - Hold duration t (creep)
 - » High reproducibility of the actuation load (intensity, location on the beam)



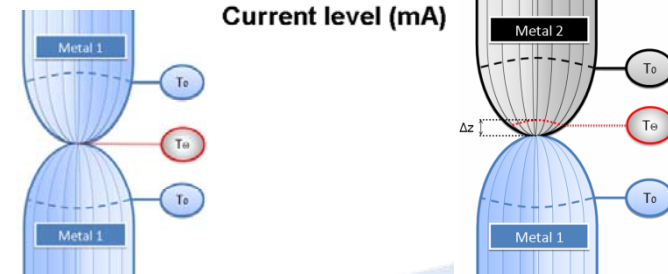
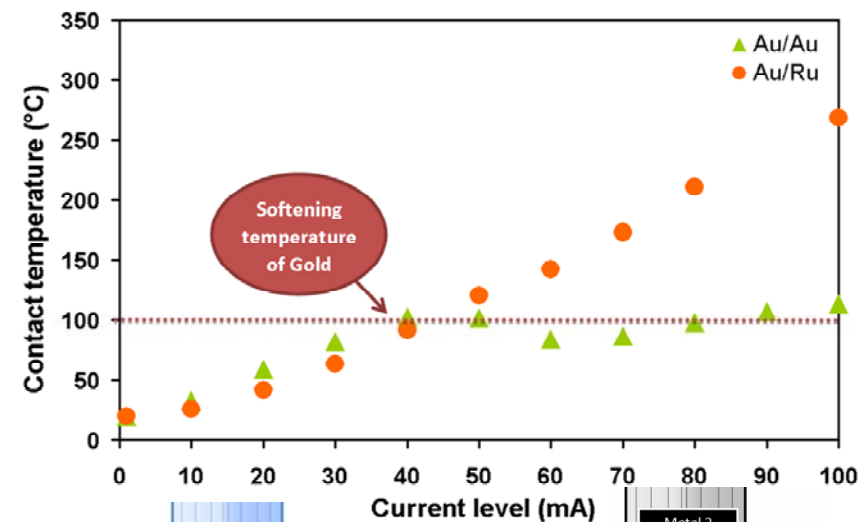


Physics of Failure

- Electrical contact (subsystem level)
 - » Select the best contact material



- » Investigate power handling capability

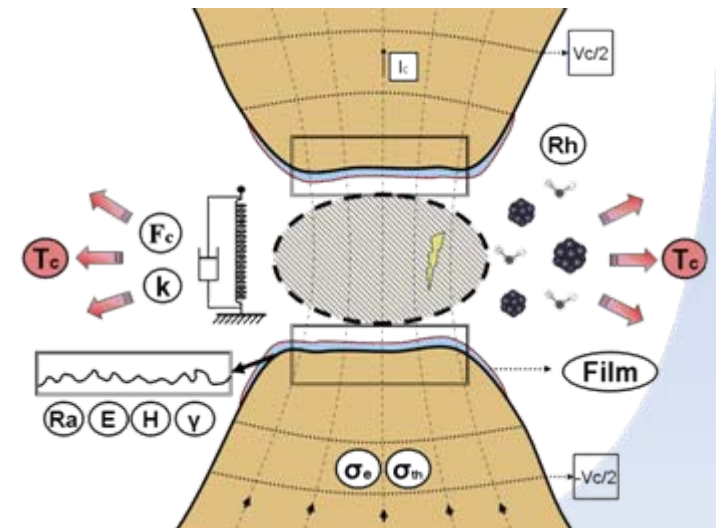
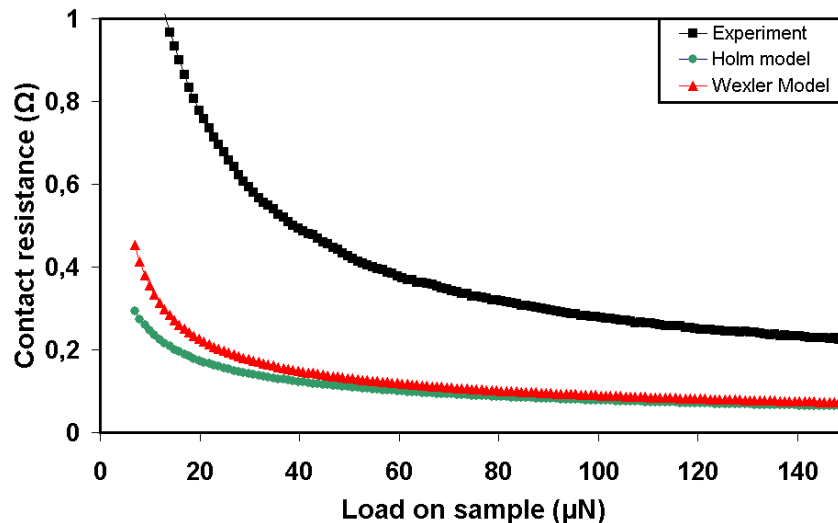


A. Broué et al., *Characterization of Au/Au, Au/Ru and Ru/Ru ohmic contacts in MEMS Switches improved by a novel methodology.* MOEMS/MEMS 2010, SF, CA.



Physics of Failure

- Electrical contact (subsystem level)
 - » Modeling of electrical resistance vs. load applied
 - Great influence of contaminant films





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Conclusion

- Contact Material:
 - » Performances of the electrical contact strongly linked with the materials used to perform the contact
 - » Trade-off between mechanical and electrical performances to reach the best reliable operations : “**Design for reliability**”
 - » Contact material have to be :
 - Good electrical conductor for low loss
 - High melting point to handle power
 - Appropriate hardness to avoid stiction phenomenon
 - Chemical inertness to avoid oxidation
 - Specific experiments and methods developed, but...
- ➔ Characterization only. Which standards for a qualification ?